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Publications List

1. “*Study of annealing and exchange bias effects in PtMn based magnetic tunnel Junction system*” , **T. Y. Peng**, Y. D. Yao, S. Y. Chen, Y. H. Wang, W. C. Chen, M. J. Gao, and D. D. Tang, **Phys. Stat. Sol. C** **1**, 3628 (2004)
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3. “*Effects of Os layer on magnetic properties of CoFe/IrMn*”, **Tai-Yen Peng**, C. K. Lo, S. Y. Chen, and Y. D. Yao, **J. Appl. Phys.** **99**, 08C907 (2006) (SCI paper)
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